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Message

DOCKET GS149

Please see attached: Amendment After Final Rejection

Amendment after Final Rejection
Expedited Handling Requested - GAU 2812

CONFIDENTIALITY NOTICE

Patent Application 10/010,162

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Amendment after Final Rejection Expedited Handling Requested - GAU 2812 OFFICIAL

IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

Applicant:

Fwu-Iuan Hshieh et al.

Serial No.:

10/010,162

Filed:

November 20, 2001

Title:

Method Of Forming Narrow Trenches In Semiconductor Substrates

Art Unit:

2812

Examiner:

Angel Roman

Docket No.: GS 149

Via Facsimile 703-872-9319

Commissioner for Patents PO Box 1450 Alexandria, VA 22313-1450

<u>AMENDMENT AFTER FINAL REJECTION</u>

Sir:

In response to the Office Action dated December 29, 2003, the time for response ending on Monday, March 1, 2004 (February 29, 2004 being a Sunday), kindly amend the aboveidentified application as follows. In addition, any deficiencies may be charged to deposit account No. 50-1047.